## INDIAN INSTITUTE OF TECHNOLOGY DELHI PYL-102, MAJOR Total Marks: 40, Time: 2hr

Date: 23-11-2017

Note: The symbols used have their usual meanings. Please mention the color code in your copy (P: pink, G: green, W: white.)

| <ol> <li>In a magnetic material, domains are separated by domain walls. For what type of domain wall, the magnetization rotates in plane parallel to the plane of the wall?</li> <li>A. Bloch Wall B. Neel wall C. Both Neel and Bloch wall</li> </ol>   |
|--|
| [0.5]  |
| 2. Which of the following is true for Hall effect of a semiconductor?  The Hall voltage  |
| A. is directly proportional to charge carrier density B <sub>1</sub> is inversely proportional to charge carrier density C. does not depend on carrier density D. inversely proportional to the applied magnetic field.  |
| [0.5]  |
| 3. Mobility $\mu$ of charge carriers in a semiconductor depends on temperature following the relation $\mu \propto T^{1.5}$ .  The origin of such temperature dependence is due to   |
| A. lattice scattering B. scattering due to crystal (point/interstitial, etc.) defects impurity scattering D. carrier-carier interactions   |
| [0.5]  |
| 4. A p-n junction of Si has donor doping concentration $N_d = 10^{16} {\rm cm}^{-3}$ and acceptor doping level $N_a = 5 \times 10^{17}$ Calculate the maximum electric field in the depletion region. Assume that the depletion region extends to 300 $\mu$ m in the n-region. The dielectric permittivity of Si is $15 \times 10^{-12} {\rm F/m}$ .                                     |
|  |
| 5. A) Explain the term dielectric polarization of a material.  |
| 5) Show that Polarization $\vec{P}$ of a material is given by $\vec{P} = (\epsilon - \epsilon_0)\vec{E}$ where $\epsilon$ and $\epsilon_0$ are permittivity of the material and that of free space, respectively.  |
| C) Considering local electric field of an isotropic material given by $\vec{E_i} = \vec{E} + \frac{1}{3\epsilon_0}\vec{P}$ , find out a relation between dielectric constant and polarizability of a material.   |
| [2+2+3]  |
| Consider a p-n juncton diode where the given parameters, are $D_n = 25 \text{ cm}^2/\text{s}$ , $D_p = 10 \text{ cm}^2/\text{s}$ , $\tau_{p0} = 5 \times 10^{-7} \text{s}$ . If you were to design the diode such that $J_n = 20 \text{A/cm}^2$ and $J_p = 5 \text{A/cm}^2$ at applied bias $V_a = 650 \text{ mV}$ , what would be the required electron and hole doping concentrations? |
| $\sim$ [5  |
| 7. Draw a schematic graph to show how under the Kronig Penney model the allowed and forbidden band width changes as a function of an army Print and the schematic graph to show how under the Kronig Penney model the allowed and forbidden bands  |

width changes as a function of energy. Briefly explain the graph.

- 8. a) Mention the conditions under which a Schottky and Ohmic contacts are formed between a metal and an n-type semiconductor.
  - b) Draw an energy band diagram to show
  - i) Schottky barrier and
  - ii) built in potential for electrons

in a metal-semiconductor contact. Clearly indiciate all the relevant parameters in the diagram.

[1+2]

(9. a) For an extrinsic semicoductor, show with a schematice diagram how the carrier concentration changes as a function of temperature. b) Explain the diagram

[1+3]

10. Show that the holes in a solid have positive charge and negative effective mass.



[2+2]

- 11. 2) Explain in details the difference in the role of majority and minority carriers in a p-n junction diode and a Schottky diode.
  - b) How are the reverse saturation currents for a Schottky and p-n junction different? Explain in details. c) A Schottky diode made from Ge and tungsten junction has a saturation current density of  $10^{-11}$  A/cm<sup>2</sup>. If the cross sectional area of the diode if  $5 \times 10^{-4}$ cm<sup>2</sup>, find out at what forward bias a current of 5 mA will be achieved. Consider the ideality factor to be unity.

Consider the diodes for room temperature applications.

[2+3+1.5]

12. An external magnetic field is applied to a magnetic material of intrinsic susceptibility  $\chi_i$ . If the material of the given shape has a demagnatization factor of N, show that the measured susceptibility  $\chi_m$  would be given by  $\chi_m = \frac{\chi_i}{1+N\chi_i}$ 

[2]

13. a) Write the Hamiltonian for a ferromagnet placed in an external magnetic field  $\vec{B}$ . If  $\vec{B_{mf}}$  is the molecular field acting in the system, show that the effective Hamiltonian can be written as  $\hat{H} = g\mu_B \sum_i \vec{S_i} \cdot (\vec{B} + \vec{B}_{mf})$ . All the symbols have their usual meanings.

[1+2]

 $k_{\rm B} = 1.38 \times 10 - 23~{\rm J/K}, \ m_e = 9.11 \times 10^{-31} {\rm kg}, \ h = 6.626 \times 10^{-34} {\rm J-s}, \ \hbar = 1.054 \times 10^{-34} {\rm J-s}$